

Attorney Docket # 4925-163

Express Mail #EV011853747US
Patent

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of
Tao HAUUKA et al.
Serial No.: n/a
Filed: concurrently
For: SIP-LEVEL CONFIDENTIALITY
PROTECTION



INFORMATION DISCLOSURE STATEMENT


Assistant Commissioner for Patents
Washington, D.C. 20231

S I R:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO 1449. Copies of the listed documents are also enclosed.

It is respectfully requested that the above information be considered by the Examiner and that the copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

Respectfully submitted,
COHEN, PONTANI, LIEBERMAN & PAVANE

By 

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Dated: November 20, 2001

U. S. DEPARTMENT OF COMMERCE
Sheet 1 of 1

PATENT AND TRADEMARK OFFICE

LIST OF REFERENCES CITED BY APPLICANT

Atty Docket No.: 4925-163
Serial No.: n/a
Applicant: Tao HAUKKA et al.

Filing Date: concurrently

Group Art:

11002 U.S. PTO
09/989806
11/20/01

U.S. PATENT DOCUMENTS

*Ex. Intls.		Document No.	Date	Name	Class	Subclass	Filing Date
	AA						
	AB						
	AC						
	AD						
	AE						

FOREIGN PATENT DOCUMENTS

*Ex. Intls.		Document No.	Date	Country	Name	Class	Subclass	Translation Yes/No
	AF							
	AG							
	AH							
	AI							

OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

	AJ		3 rd Generation Partnership Partnership Project; Technical Specification Group SA 3; Access Security for IP-Based Services (Release 5) , 2000, PP. 1-31
	AK		
	AL		

EXAMINER: _____

DATE CONSIDERED: _____

* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.